



09/869,264, 080502
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PATENT
Customer No. 22,852
Attorney Docket No. 1197-226

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)
)
Shinji Aki et al.) Group Art Unit: Not Yet Assigned
)
Application No.: 09/869,264) Examiner: Not Yet Assigned
)
Filed: June 27, 2001)
)
For: Process for Producing Carbostyryl)
Derivatives)
)

Assistant Commissioner for Patents
Washington, DC 20231

Sir:

PRELIMINARY AMENDMENT

Prior to the examination of the above application, please amend this application as follows:

IN THE SPECIFICATION:

Page 3, replace the paragraph beginning on line 2 with the following new paragraph:

According to the above-mentioned known process, the yield of the compound of general formula (I) is as low as about 50 to 74%, because there is also formed a compound in which the tetrazole derivative of general formula (III') has reacted not only with the hydroxyl group of the carbostyryl derivative of general formula (II) but also with the 1-position of the carbostyryl derivative of general formula (I) simultaneously. Since the thus formed contaminative impurity is difficult to remove, production of a compound of general formula (I) having a high purity has required a complicated process of purification.

LAW OFFICES

FINNEGAN, HENDERSON,
FARABOW, GARRETT,
& DUNNER, L.L.P.
1300 I STREET, N. W.
WASHINGTON, DC 20005
202-408-4000